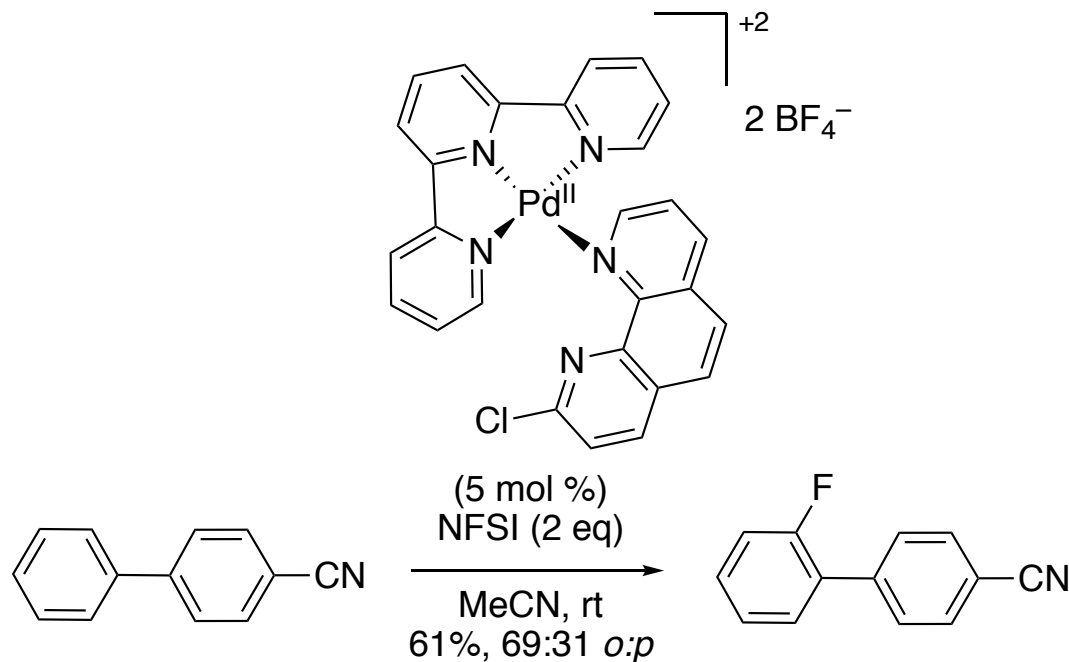


# Palladium-Catalyzed Electrophilic Aromatic C–H Fluorination



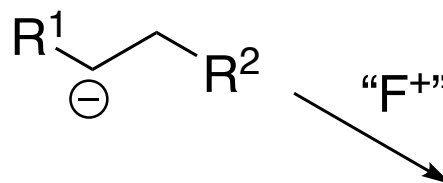
Yamamoto, K; Li, J.; Garber, J. A. O.; Rolfes, J. D.; Boursalian, G. B.; Borghs, J. C.; Genicot, C.; Jacq, J.; van Gastel, M.; Neese, F.; Ritter, T.  
*Nature* **2018**, *554*, 511-514

John Milligan  
Wipf Group Meeting

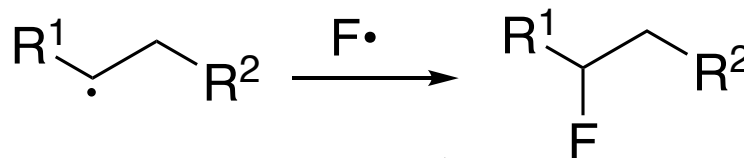
Current Literature  
March 17, 2018

# Fluorination

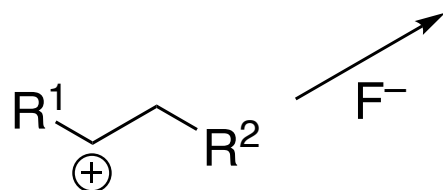
**Electrophilic fluorination**  
(Selectfluor, NFSI, etc.)



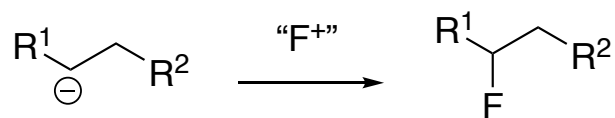
**Radical fluorination**  
(above reagents under  
radical formation conditions)



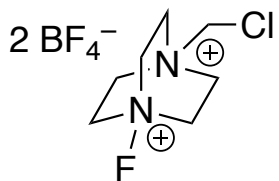
**Nucleophilic fluorination**  
(HF·pyridine, F<sup>-</sup> salts;  
also deoxyfluorination reagents  
such as DAST, Deoxofluor, PyFluor)



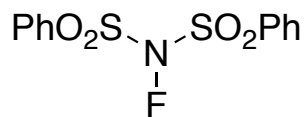
**Electrophilic fluorination**



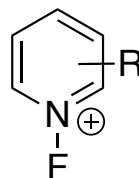
Representative reagents:



**Selectfluor™**



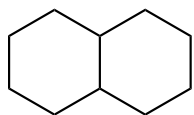
**NFSI**



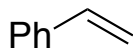
**fluoropyridinium salts**

**XeF<sub>2</sub>** (expensive)

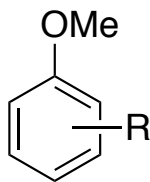
Representative substrates:



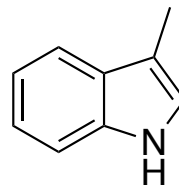
**alkanes**  
(w/ heating)



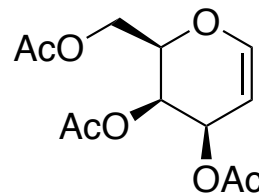
**alkenes/  
alkynes**



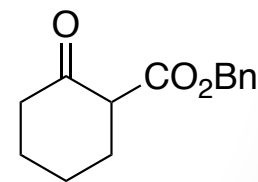
**activated  
arenes**



**activated  
heterocycles**

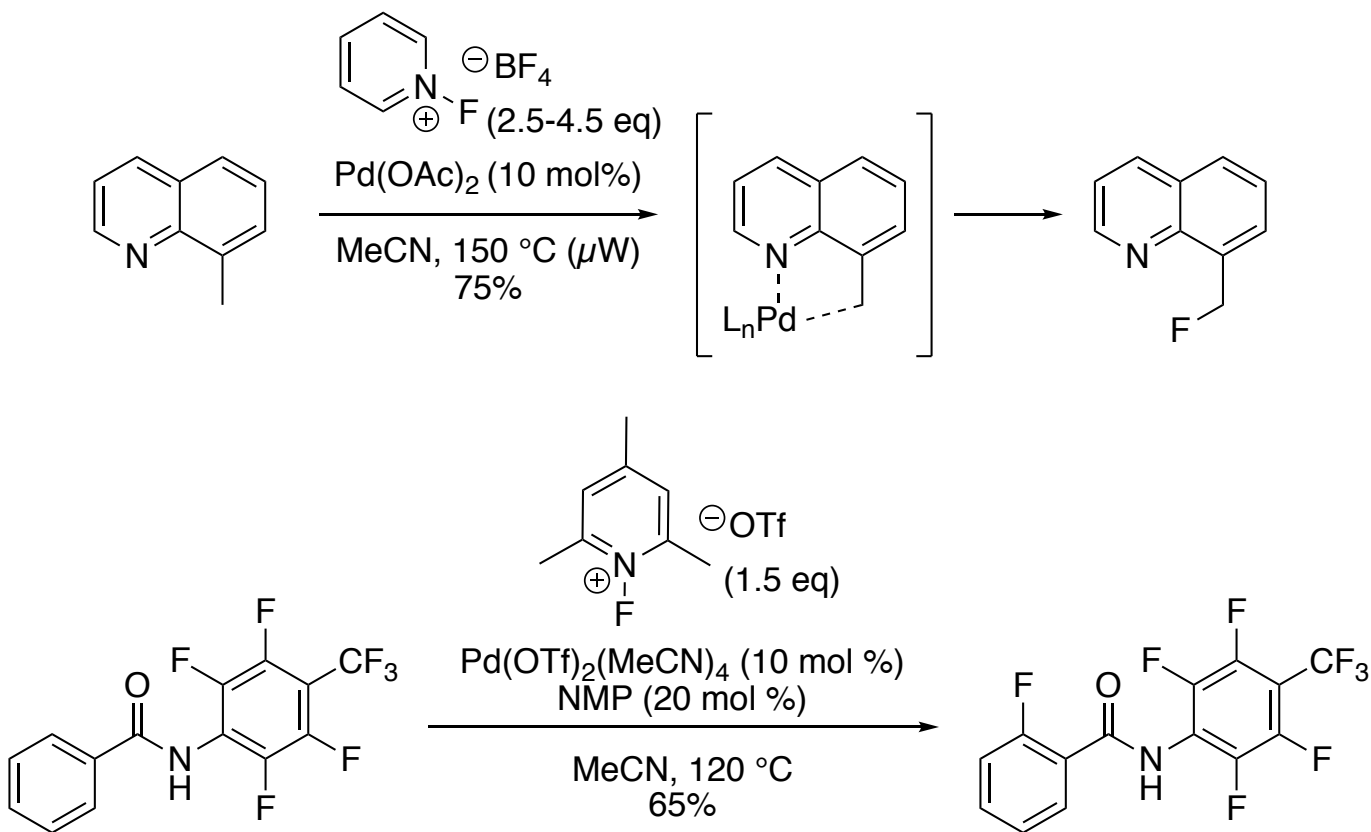


**glycals/  
enol ethers/  
enamines**



**1,3-dicarbonyl  
compounds**

# Catalytic, Electrophilic C–H Fluorination

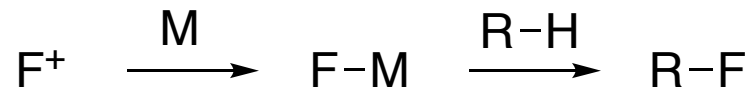


# Concept of Current Work

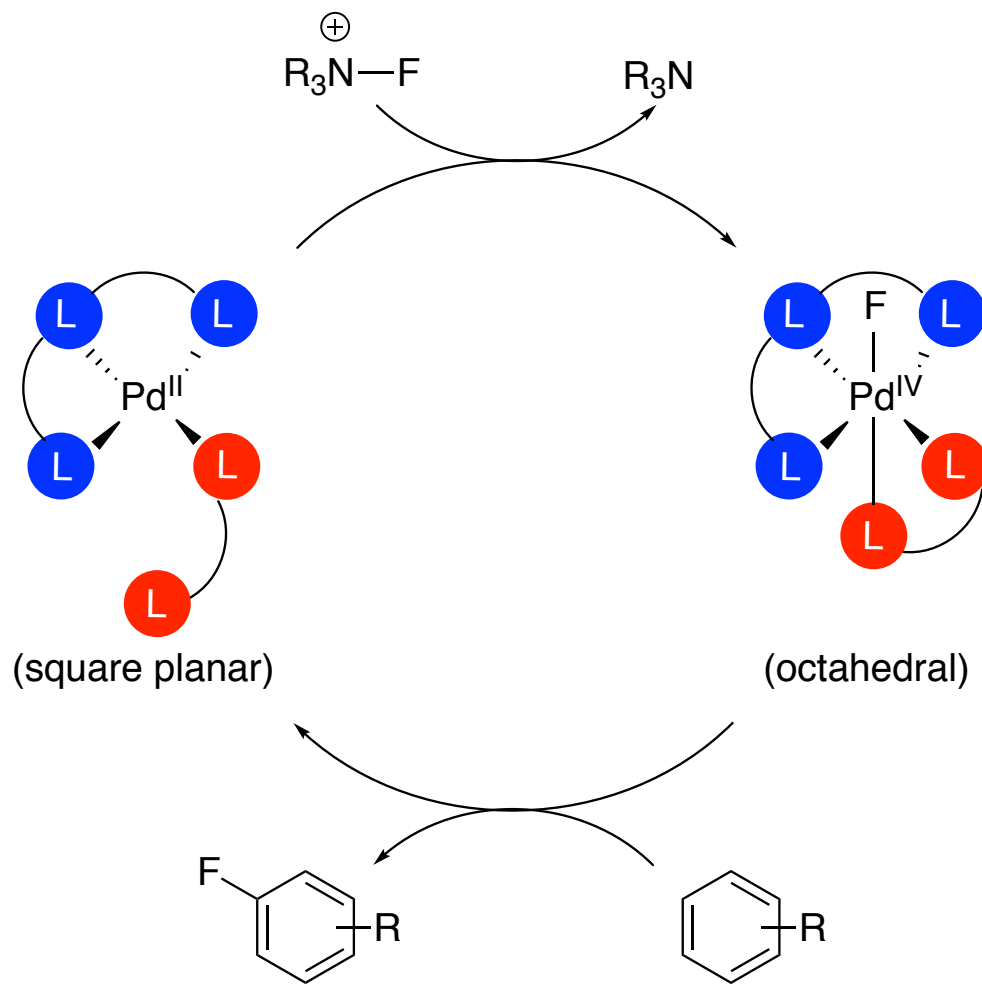
**Previous Approaches: Fluorination of a C–M bond**



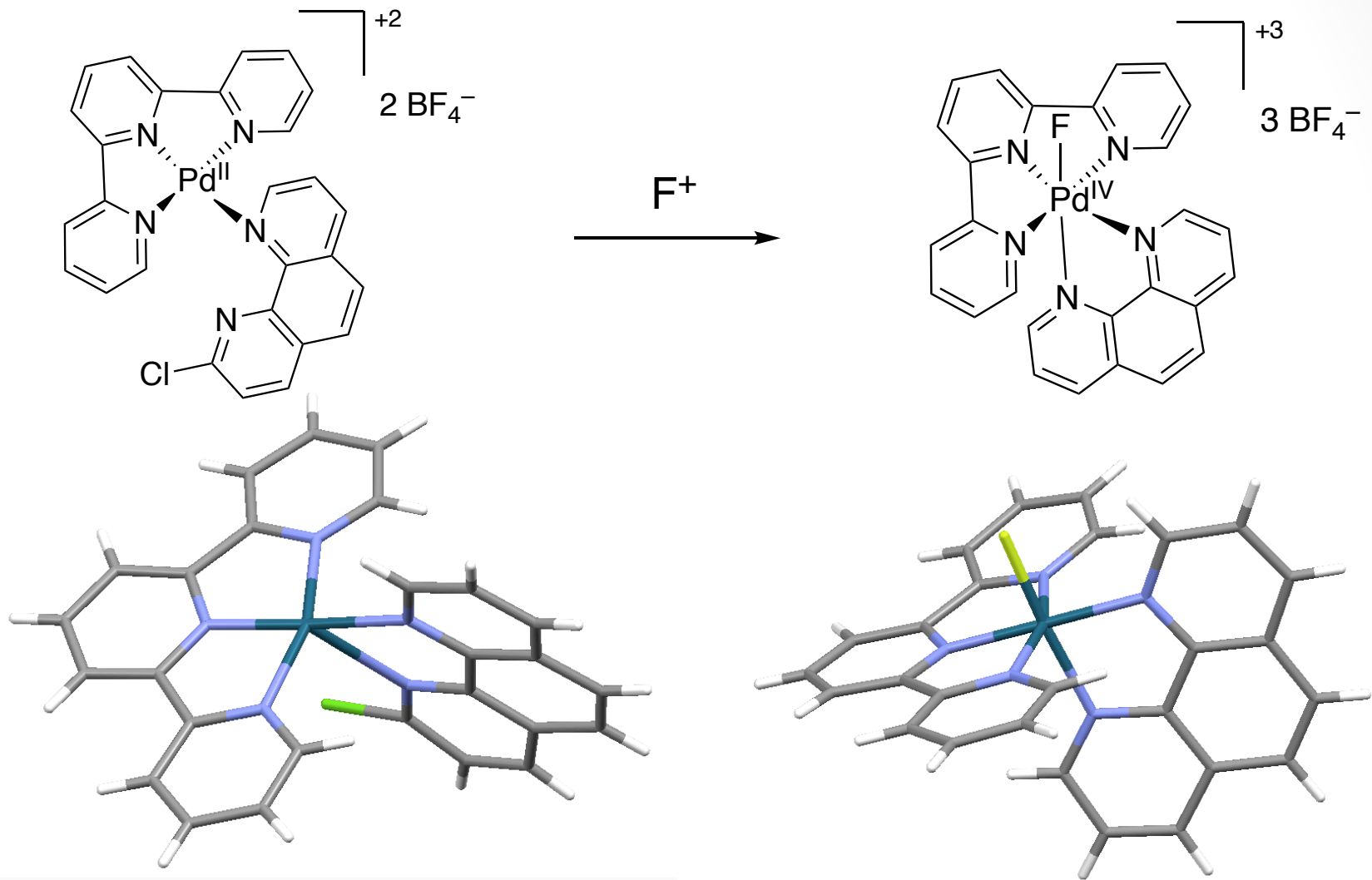
**This Work: Formation of a highly electrophilic M–F species**



# Concept of Current Work

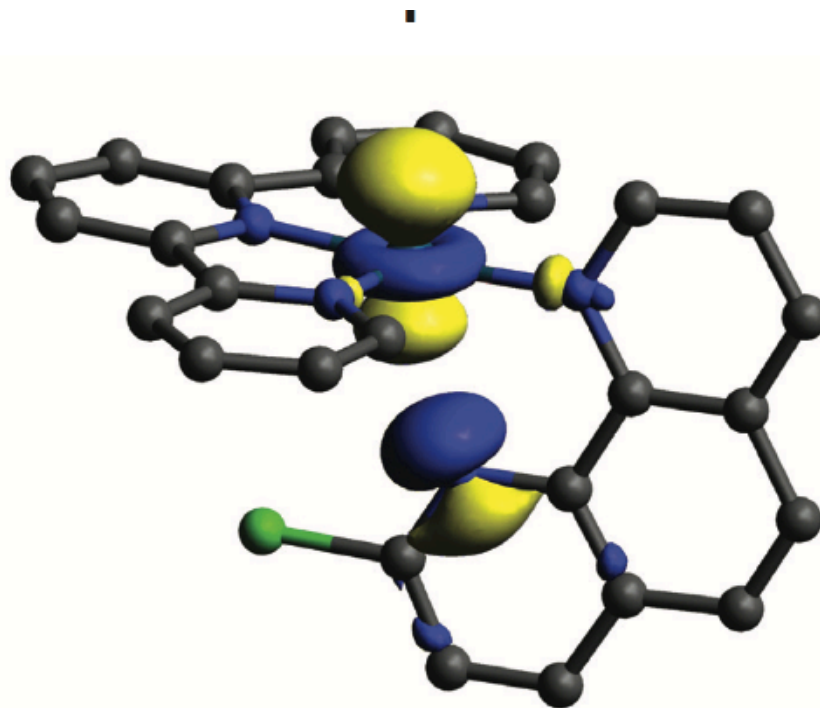
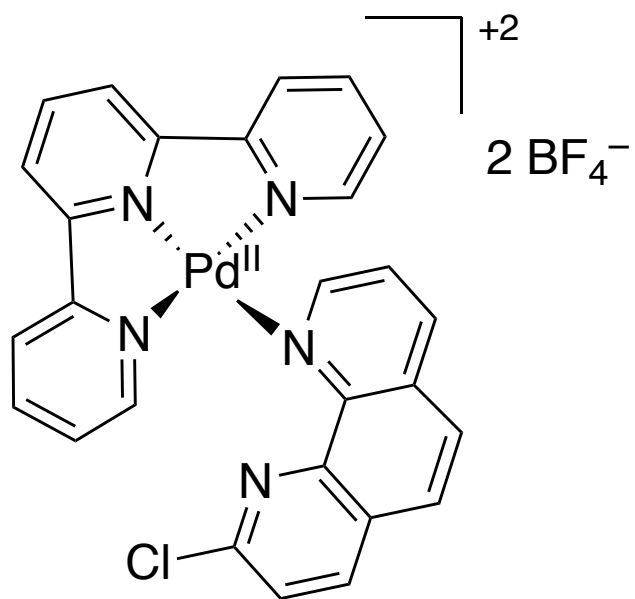


# Palladium complexes



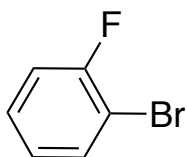
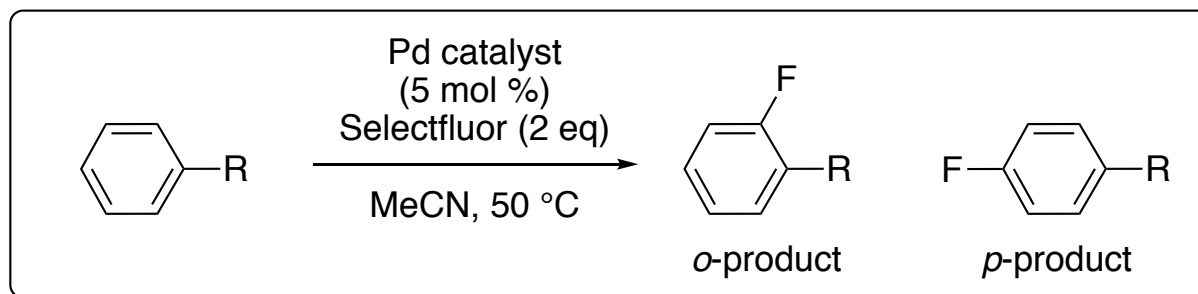
CCDC #1465063, 1536794

# Catalyst HOMO

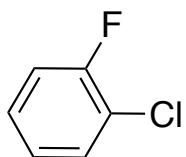




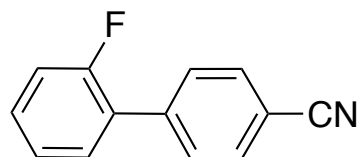
# Substrate Scope



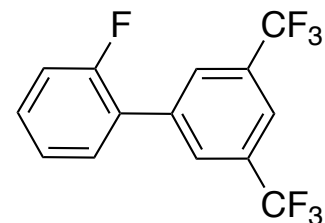
49%, 52:48 *o:p*



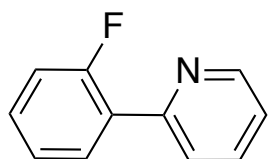
51%, 59:41 *o:p*



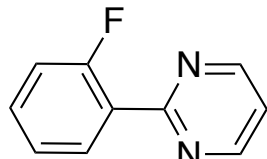
61%, 69:31 *o:p*



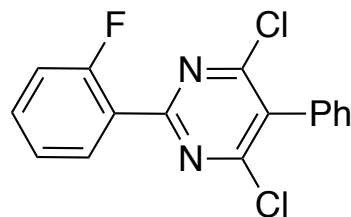
85%, 69:31 *o:p*



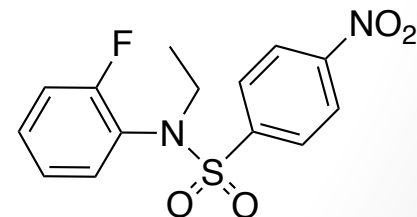
55%, 77:23 *o:p*



46%, 67:33 *o:p*

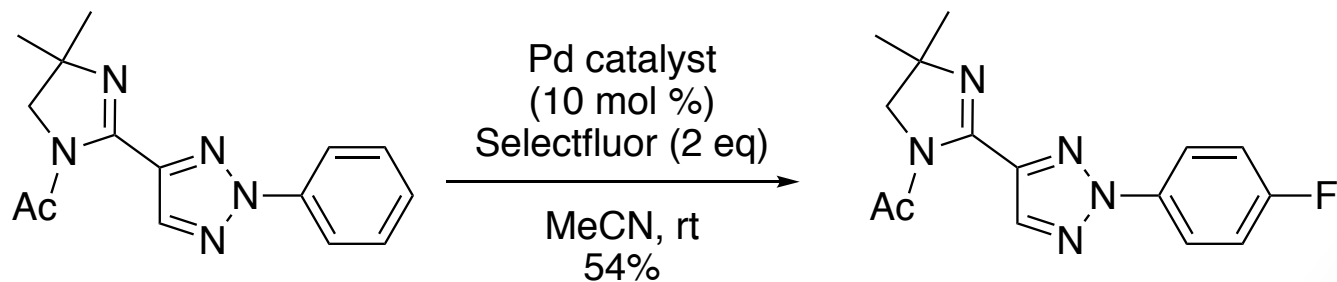
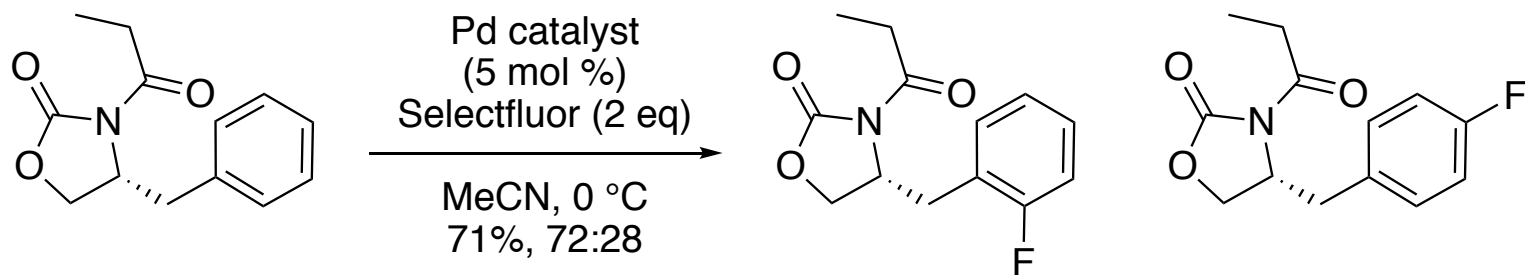
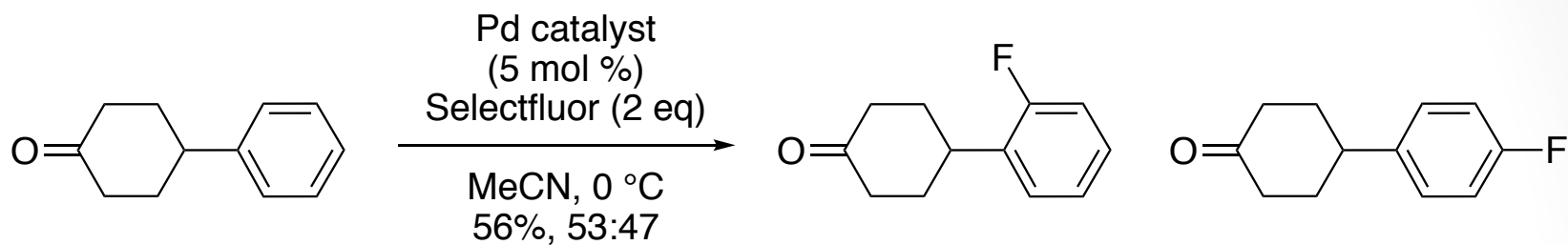


51%, 59:41 *o:p*

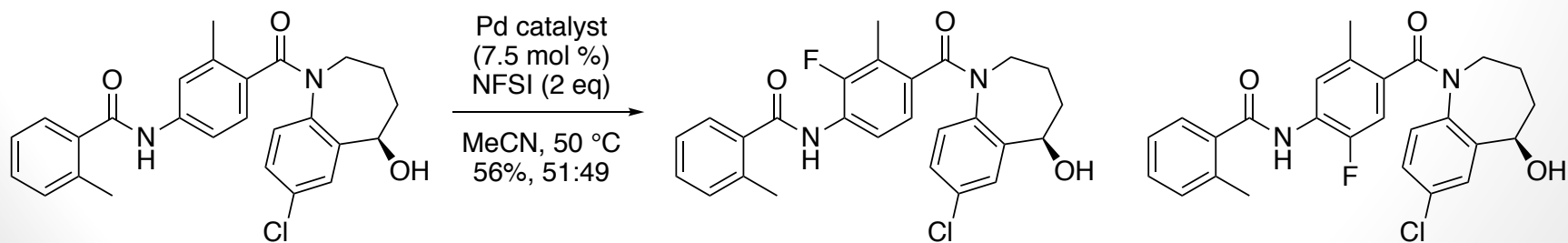
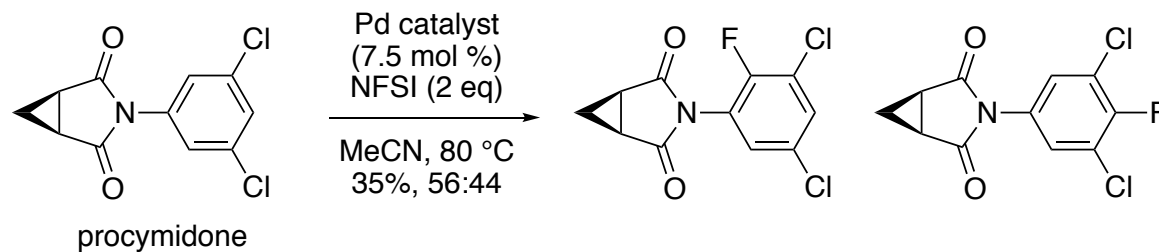
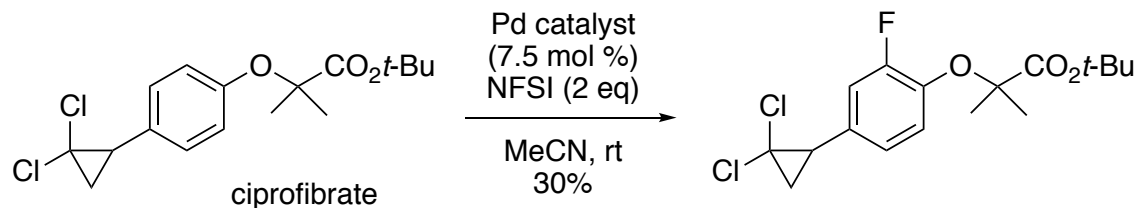
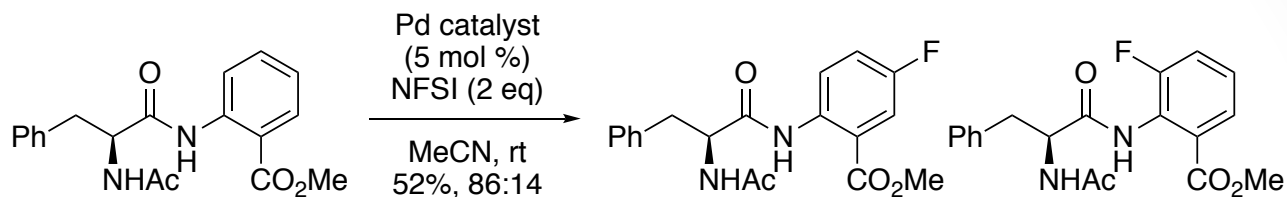


60%, 49:51 *o:p*

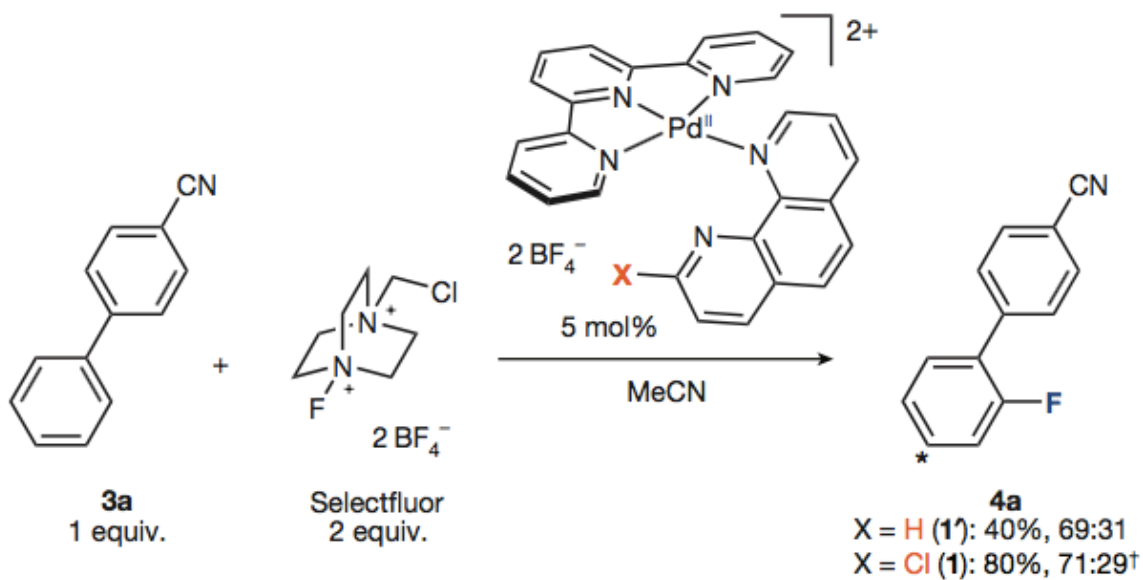
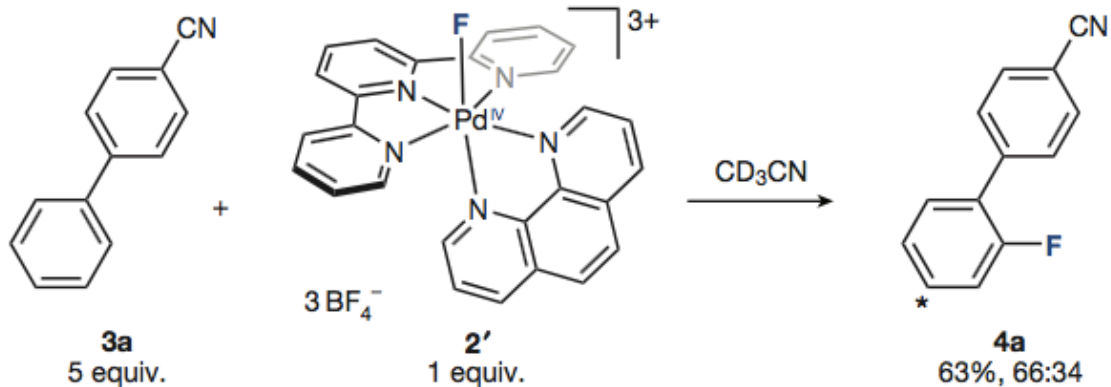
# Functional Group Tolerance



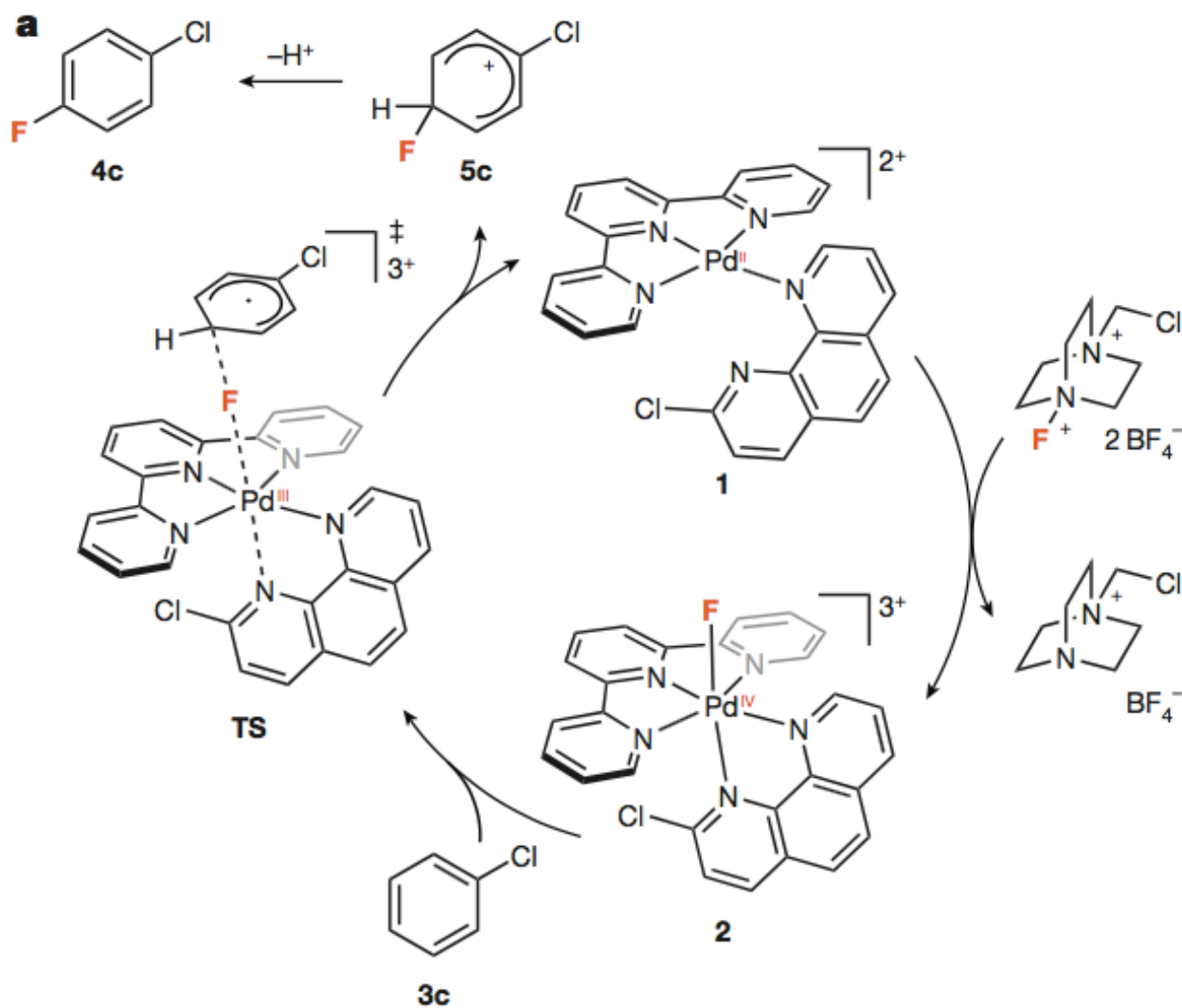
# NFSI reactions



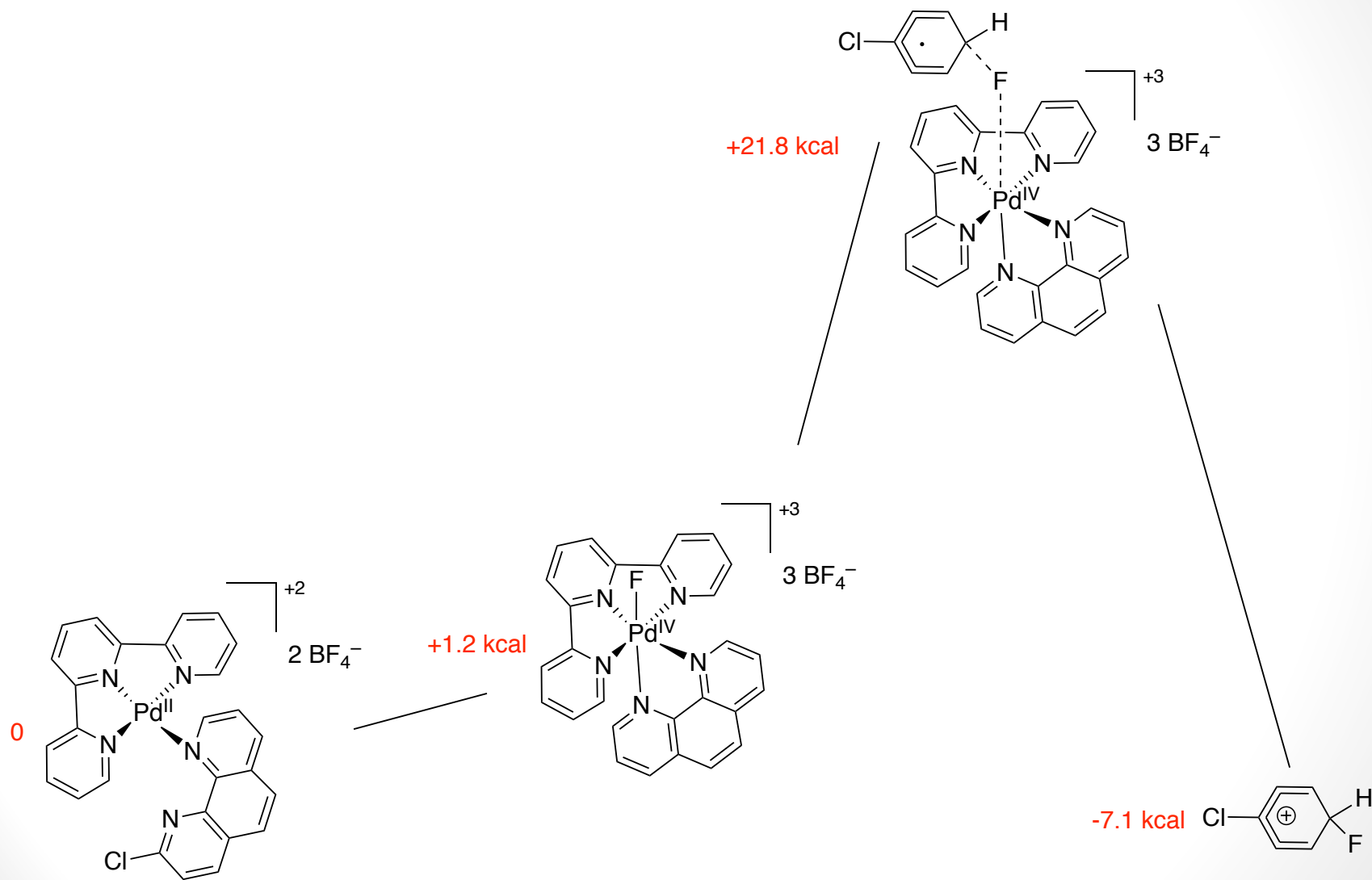
# Comparison Study



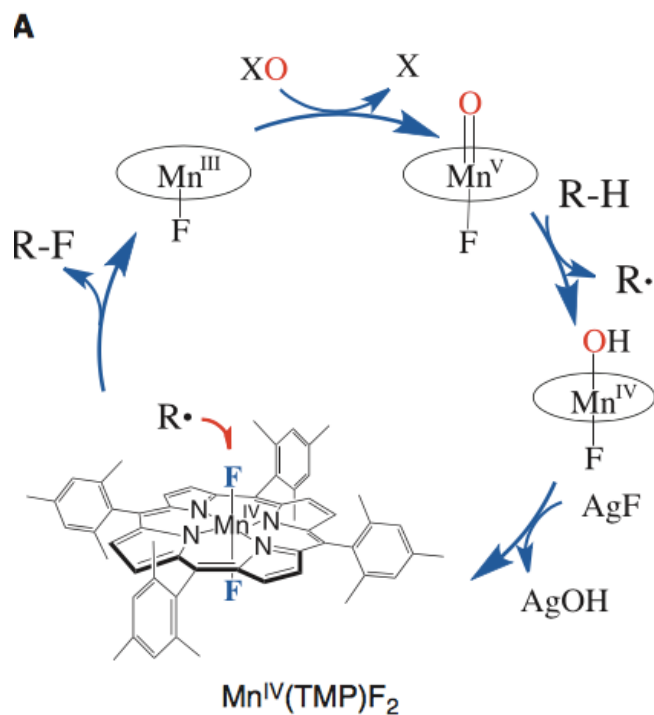
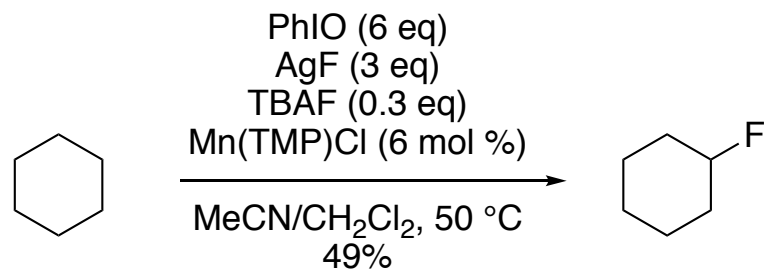
# Mechanism: Electron Transfer



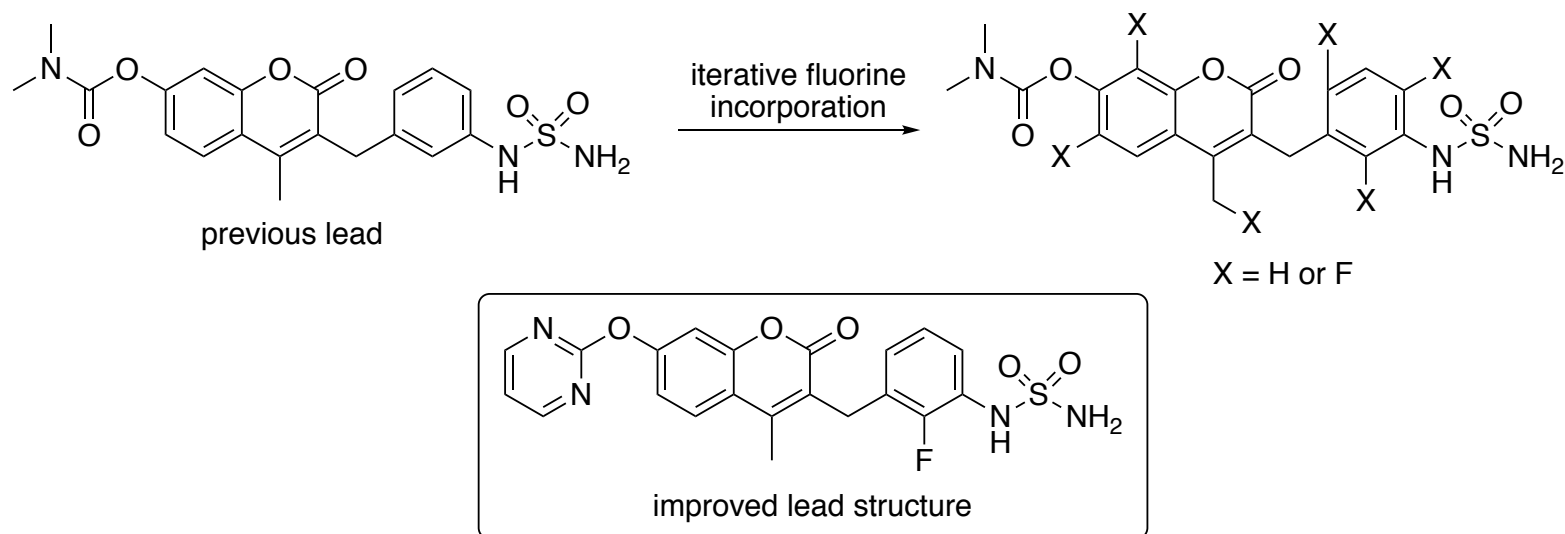
# Computational Mechanistic Studies



# Comparison: Radical-Based C-H Fluorination

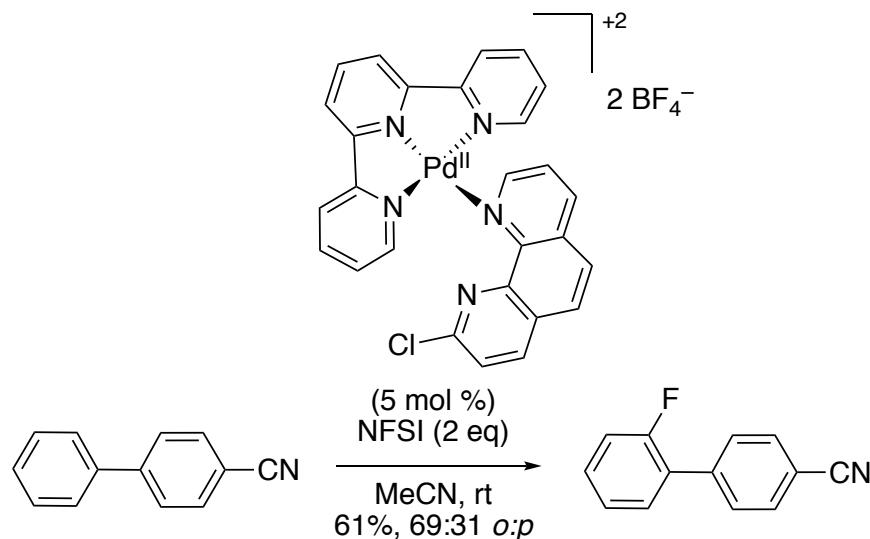


# Potential Application: Fluoride Scanning





# Summary



- This new method enables the electrophilic fluorination previously unsuitable substrates
- Amenable for late stage fluorination
- Future opportunities: Design of catalysts with high selectivity